

Model of SAM-based molecular diodes made of ferrocenyl- alkanethiols

David Duché, Ujwol Planchoke, Florian-Xuan Dang, Judikaël Le Rouzo, Marc Bescond, Jean-Jacques Simon, Teodor Silviu Balaban, Ludovic Escoubas

▶ To cite this version:

David Duché, Ujwol Planchoke, Florian-Xuan Dang, Judikaël Le Rouzo, Marc Bescond, et al.. Model of SAM-based molecular diodes made of ferrocenyl- alkanethiols. Journal of Applied Physics, 2017, $121\ (11)$, 10.1063/1.4978764. hal-01788946

HAL Id: hal-01788946 https://amu.hal.science/hal-01788946

Submitted on 9 May 2018

HAL is a multi-disciplinary open access archive for the deposit and dissemination of scientific research documents, whether they are published or not. The documents may come from teaching and research institutions in France or abroad, or from public or private research centers.

L'archive ouverte pluridisciplinaire **HAL**, est destinée au dépôt et à la diffusion de documents scientifiques de niveau recherche, publiés ou non, émanant des établissements d'enseignement et de recherche français ou étrangers, des laboratoires publics ou privés.

Model of SAM-based molecular diodes made of ferrocenylalkanethiols

David Duche^{1, a)}, Ujwol Planchoke¹, Florian-Xuan Dang², Judikael Le Rouzo¹, MarcBescond¹, Jean-Jacques Simon¹, TeodorSilviu Balaban², and Ludovic Escoubas ¹

There has been significant work investigating the use of self assembled monolayers (SAM) made of ferrocenyl terminated alkanethiols for realizing molecular diodes leading to remarkably large forward-to-reverse current rectification ratios. In this study, we use a multi band barrier tunneling model to examine the electrical properties of SAM-based molecular diodes made of HSC_9Fc , $HSC_{11}Fc$ and HSC_iFcC_{13-i} ($0 \le i \le 13$). Using our simple physical model, we reproduce the experimental data of charge transport across various ferrocenyl substituted alkanethiols performed by Nijhuis, Reus and Whitesides (J. AM. CHEM. SOC. 2010, 132, 18386-184016) and L. Yuan and al. (Nature Communication 2015, 6:6324). Especially, the model allows predicting the rectification direction in HSC_iFcC_{13-i} ($0 \le i \le 13$) based molecular diodes depending on the position of the ferrocenyl (Fc) moiety within the molecules. We show that the asymmetry of barrier length at both sides of the Highest Occupied Molecular Orbital (HOMO) of the ferrocenyl moiety strongly contributes to the rectifying properties of ferrocenyl-alkanethiol based molecular junctions. Furthermore, our results reveal that bound and quasi-bound states play an important role in the charge transport.

I. Introduction

In 1974, A. Aviram and M. A. Ratner¹ proposed the concept of a molecular diode. It is based on the idea that a molecule composed of a donor (D) group and an acceptor (A) group linked together by a σ bridge (a D- σ -A compound) would exhibit a natural rectification behavior. Since these first works, numerous researches related to molecular electronics have been carried

¹ Aix Marseille Universite, CNRS, Universite de Toulon, IM2NP UMR 7334, 13397, Marseille, France

² Aix-Marseille Universite, CNRS UMR 7313, Institut des Sciences Moleculaires de Marseille, Chirosciences, Service 442, Avenue Escadrille Normandie-Niemen, F-13013 Marseille, France.

^{*}david.duche@im2np.fr

out as this field promises the development of new nanoscale electronic components²⁻⁴. Molecular diodes functionalized with thiol linkers provide strong advantages due to their ability to form self assembled monolayers (SAMs) covalently bound at the surface of noble metals (Ag, Au). It allows heterometallicnanogaps to be associated with organic molecules exhibiting diode behavior⁵. Furthermore, self-assembled molecular diodes can be coated at the surface of arrays of metallic nanostructures (nano-particles or nano-antennas) aiming at obtaining opto-electronic devices such as sensors⁶, selective filters⁷ or nano-rectennas^{8,9}.

Molecular diodes made of ferrocenyl-containing alkanethiols are of great interest since they exhibit strong asymmetries leading to remarkably large forward-to-reverse current rectification ratios. The forward-to-reverse current rectification ratios (RR) can be used as a figure of merit to evaluate the rectifying properties of the molecular diodes. In our study, RR is defined as the ratio between the current at -1V and at 1V:

$$R = \frac{|J(-1V)|}{|J(1V)|} \tag{1}$$

Where |J(±1V)| is the absolute value of the current density (A/cm²). Nijhuis, Reus and Whitesides¹⁰ and L. Yuan et al.¹¹ obtained RR greater than 100 using ferrocenyl-alkanethiols based molecular diodes in which both electrodes exhibited similar work functions. In this case, the rectification process was not governed by the work function difference between the electrodes but was due to the intrinsic rectifying properties of ferrocenyl-alkanethiols. Furthermore, L. Yuan et al.¹¹ experimentally showed very recently that a control of the direction of rectification is possible by placing the Fc units of ferrocenyl-alkanethiols (HSC_iFcC_{13-i}) at different positions within the alkyl chain.

In this study, we develop a multiband quantum transport model based on a matrix formulation¹² in which we consider both the HOMO (Highest Occupied Molecular Orbital) and LUMO (Lowest Unoccupied Molecular Orbital) levels, and examine the electrical properties of the molecular junctions made of ferrocenyl-alkanethiols. The image potential in the potential barriers is also included in our model. We compare the computed current versus bias voltage I(Va) of the diodes under darkness with experimental measurements obtained by Nijhuis, Reus and Whitesides¹⁰ and we give an insight into the physical phenomena occurring in ferrocenyl-alkanethiols based molecular diodes. Especially, we investigate through simulation how bound and quasi-bound states of the electronic levels of the molecules can participate to the charge

transport. After this introduction, the second section of the paper is devoted to the description of the model developed to study the electrical properties of the molecular diodes. The third section is dedicated to the simulation of the electrical properties of HSC_9Fc and $HSC_{11}Fc$ based molecular diodes. We investigate the influence of the HOMO and the LUMO energy bands of the ferrocen moiety and the alkyl chain length on the electrical properties of the diodes. In the forth section, we discuss the rectifying properties of HSC_iFcC_{13-i} ($0 \le i \le 13$) based molecular diodes depending of the position of the ferrocene (Fc) moiety within the molecules.

II. Model

In order to help the understanding, we consider the specific case of a 11-(ferrocenyl)-1undecane-thiol (HSC₁₁Fc) based molecular diode. As it is depicted in figure 1(a) and 1(b), we consider a self assembled monolayer (SAM) of SC₁₁Fc sandwiched between two electrodes and forming a Metal-SAM-Metal diode. The first electrode is made of silver (Ag). The SAM is bound to the Ag electrode by covalent bounds between the sulfur and the Ag atoms (Ag-S). The second Ga₂O₃-EGaIn electrode is an eutectic liquid electrode usually used to fabricate molecular diodes. It is generally assumed that the terminated Fc moities of the SAM form a Van der Walls contact with the Ga_2O_3 -EGaIn electrode 10,11 . The figure 1(b) gives the theoretical band diagram (with respect to vacuum) of the resulting Ag-SC₁₁Fc-Ga₂O₃-EgGaIn molecular junction before the alignment of the Fermi levels. Both electrodes are defined by their work functions allowing us to determine the Fermi level of the electrons in the metals. The alkyl chain of the molecule exhibits a large band gap with an HOMO well below the Fermi level of each electrode 13. For this reason, the HOMO of the alkyl chain does not participate to the charge transportation and only the LUMO will be considered in the following. The ferrocenyl moieties are considered to be semiconductive exhibiting HOMO and LUMO levels quite close to the Fermi level of each electrode. The exact position of the energy levels and their broadening will be discussed in detail in the section III.

We used a quantum transport model to examine the electrical properties of the molecular junctions. An electron is emitted from one of the two electrodes with a total energy E and is transferred through the potential barriers to the other electrode. The wave functions of the electron (Ψ) are given by the solutions of the time-independent Schrodinger equation. In the lack

of an experimental estimate, the effective mass of the electron in the tunneling junction is assumed to be equal to the free electron mass (m_0) .

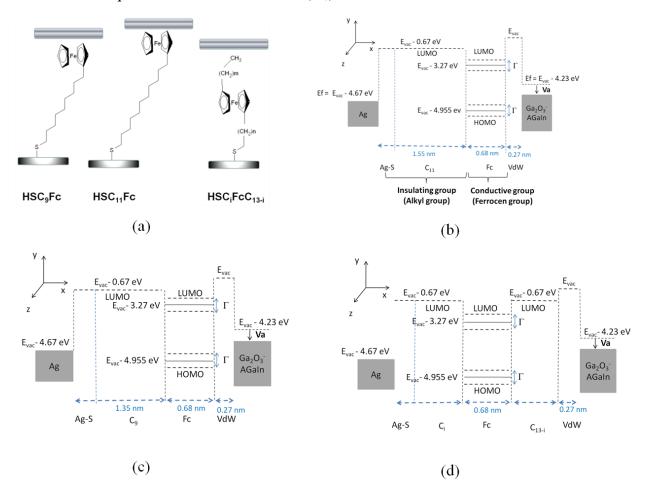


FIG.1. (a) Schematic representation of molecular diodes made of ferrocenyl-containing alkanethiols. It Consists in Ag bottom electrodes, SAM of SC₉Fc, SC₁₁Fc or SC_iFcC₁₃-i and Ga2O3-EGaIn electrodes. Theoretical energy band diagram of molecular diodes made of (b) HSC₁₁Fc, (c) HSC₉FC and (d) HSC_iFcC₁₃-i.

A. Calculation of the barrier potential within the tunneling junction:

The potential in the tunnel junction was considered to be invariant along both the transverse y and z axes. We assume the Fermi level of the left electrode to be 10 eV but, as we will see in the following, the electrical properties of the diodes essentially depend on the energy relative to the vacuum level¹⁴. The potential variation (V(x)) within the junctions has been expressed as follows:

$$V(x) = W_L + \Delta \Phi + \frac{[(W_R - W_L) - qV_a]x}{d} + V_{image}$$
 (2)

where x is the distance of the electron from the left electrode, q is the elementary charge, d is the distance separating the two electrodes, $W_L=W_{Ag}$ and $W_R=W_{Ga2O3-EgGaIn}$ are the work functions of the left silver electrode and the right Ga_2O_3 -EgGaInelectrode respectively. Va is the applied voltage (cf. figure 1). The Va parameter is required in order to compute the I(Va) characteristics of the diodes and to examine their rectifying properties. In our model, we consider that a positive bias induces a decrease of the Fermi level of the right electrode and results in an additional potential within the junction. $\Delta\Phi$ is the energy difference between the work function of the left Ag electrode and the molecular orbital (HOMO or LUMO) of the functional groups located within the molecular junction. Within the Van der Waals' contacting, $\Delta\Phi$ is defined as the energy difference between the work function of the left electrode and the vacuum level. Because the relative dielectric constant of organic materials is low (~ 2), the image potential screening is weak within the molecular junctions ^{15,16}. Thus, an electron in the vicinity of an electrode "feels" an additional image potential, which results in barrier lowering. The solution of the image force problem results in an expression for the image potential $V_{image}(x)$ which is an infinite serie¹⁷:

$$V_{image}(x) = -\left(\frac{q^2}{4\pi\varepsilon_0\varepsilon_r}\right)\left[\frac{1}{2x} + \sum_{n=1}^{\infty} \frac{nd}{(nd)^2 - x^2} - \frac{1}{nd}\right]$$
(3)

Where ε_0 and ε_r are the dielectric constant of the vacuum and the relative dielectric constant of the organic material within the junctions, respectively. The relative dielectric constant of the ferrocenyl-alkanethiols has been considered to be equal to the dielectric constant of the alkyl chains $(\varepsilon_r = 2.1)^{15}$. This expression can be accurately expressed by an hyperbolic function as follows ^{17,18}:

$$V_{image}(x) = -1.15. \frac{q^2 \ln(2)}{8\pi\varepsilon_0 \varepsilon_{\rm rd}} \cdot \frac{d^2}{x(d-x)}$$
(4)

B. Calculation of the current density through the tunnel junction:

Assuming an isotropic distribution of electron velocities in the metal electrodes, the tunneling current density through the junction can be calculated from the tunneling probability T ^{14,17,19}:

$$I = \frac{4\pi m_0 q}{h^3} \int_{-\infty}^{\infty} T(E_x) dE_x \int_{E_x}^{\infty} [f_L(E) - f_R(E + qV_a)] dE$$
 (5)

Where T is calculated using a matrix formalism 12 . The Fermi-Dirac distribution functions under bias in the left (f $_{\rm L}$) and in the right (f $_{\rm R}$) electrode are given by the following formula 17 :

$$f_L(E) = \frac{1}{1 + e^{\frac{E - E_{FL}}{KT}}} \tag{6}$$

$$f_L(E) = \frac{1}{1 + e^{\frac{E - (E_{FL} - qV_a)}{KT}}}$$
 (7)

Due to the semi-conducting character of the ferrocenyl moiety, both the HOMO and the LUMO have to be considered. In our model, the contributions of the two levels are calculated separately. First, the tunneling current density J_{HOMO} is calculated by considering only the HOMO of the ferrocenyl moiety. In the same manner, the tunneling current density J_{LUMO} is calculated by considering only the LUMO of the ferrocenyl moiety. Finally both tunneling current densities are added to obtain the total tunneling current density:

$$J = J_{HOMO} + J_{LUMO} \tag{8}$$

We have then implemented a ballistic transport model in which the energy E of an electron injected from the electrode remains constant along the active region of the system. Inelastic scattering phenomena, like interactions of electrons with phonons, are neglected. The simplicity of our physical model is an asset to give an insight into the physical phenomena occurring in molecular diodes. Furthermore, such a simple model does not require high computation resources and could be used for the optimization of the electrical properties of molecular diodes²⁰.

III. HSC11Fc and HSC9Fc based molecular diodes

We consider now an $HSC_{11}Fc$ based self-assembled molecular diode in the following configuration: $Ag/SAM/Ga_2O_3$ -EGaIn. The shape of the potential barrier depends on the workfunctions of the electrodes, the HOMO and LUMO of the different functional groups within the ferrocenylalkanethiol and the applied voltage. Figure 1b shows the energy band diagram of the diode. In accordance with the Nijhuis, Reus and Whitesides' experimental work¹⁰, we consider metallic Ag and Ga_2O_3 -EGaIn electrodes with work functions of $W_{Ag} = 4.67$ eV and W_{Ga2O_3 -EGaIn</sub> = 4.23 eV respectively. The LUMO level of the alkyl chains is set to -0.67 eV. This value is in accordance with experimental measurements²¹ and with values obtained through numerical simulations 13,15 . The energy position of the HOMO and the LUMO of the ferrocen moieties are -3.27 eV and -4.97 eV respectively while their broadenings (Γ) is varied between 0.1 eV and 0.7 eV. These values are in accordance with numerical simulations performed using

the density functional theory(DFT) for an HSC₁₁Fc based molecular diode in which both electrodes are made of gold (Au)¹³. In the present work, starting from values extracted from ref 13, we adjust the energy position and the broadening of the HOMO and the LUMO to fit the data of Nijhuis, Reus and Whitesides' experimental work¹⁰. This adjustment is necessary because the electrical properties of the molecules are strongly influenced by the electrodes. Especially, the energy levels can be broadened within the molecular diode depending on the coupling strength between the electrons in the electrodes and those in the molecules ^{11,22}. The contacts at theAg and the Ga₂O₃-EGaIn electrodes are totally different¹⁰. It is generally assumed that the Fc end group forms a Van der Waals contact with the Ga₂O₃-EGaIn¹⁰ electrode while the sulfur forms a covalent bond with the Ag electrode. As it can be seen in the figure 1, we consider an energy barrier equals to the one of the alkyl chain for the covalent bonds. For the Van der Waals contact, we consider a barrier potential corresponding to the vacuum level.

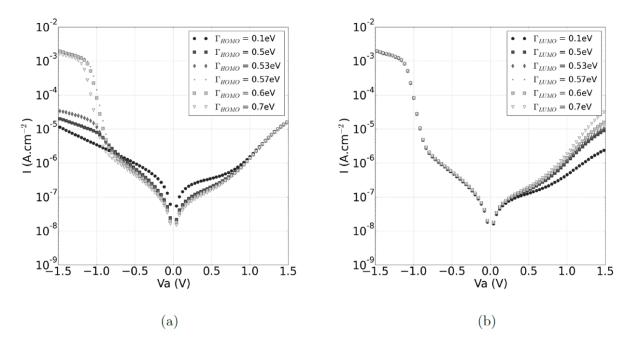


FIG.2. Influence of the the energy level broadening (a) Γ_{HOMO} and (b) Γ_{LUMO} on the calculated I(Va) characteristics of a HSC11Fc molecular diode.

A. Influence of the Γ broadening

We first investigate the influence of the energy level broadening Γ on the electrical properties of $HSC_{11}Fc$ based diodes. The broadening of both the LUMO and the HOMO is varied independently. The other parameters are kept unchanged.

The HOMO level broadening (Γ_{HOMO}) is varied from 0.1 eV to 0.7 eV while the LUMO level broadening is kept constant ($\Gamma_{LUMO} = 0.6 \text{ eV}$). The resulting calculated I(Va) characteristics are presented in figure 2(a). The HOMO level broadening mainly influences the diode electrical properties for negative applied voltages. A strong increase of the current is observed for applied voltages lower than -0.8 V when Γ_{HOMO} is upper than 0.57eV. Thus, the I(Va) characteristics are highly asymmetric. This current increase is stable for broadenings varying between 0.57 eV and 0.7 eV. On the contrary, this current increase is becoming less and less pronounced when the broadening is decreasing from 0.57 eV to 0.1 eV and the I(Va) characteristics become more and more symmetric. The figure 2(b) shows the I(Va) characteristics of the diode for different values of the LUMO level broadening (0.1 eV $\leq \Gamma_{LUMO} \leq 0.7$ eV). The LUMO level broadening mainly influences the slope of the I(Va) curves for positive applied voltages but a smaller increase of current can be observed. Thus, these calculations show that the rectification ratio is mainly influenced by the HOMO. In the following, we investigate the strong current increase occurring at negative applied voltage for the high values of the HOMO broadening. For these investigations, the LUMO broadening is fixed (Γ_{LUMO} =0.6 eV) while two different values of the HOMO broadening have been considered (Γ_{HOMO} = 0.6 eV and Γ_{HOMO} = 0.5 eV).

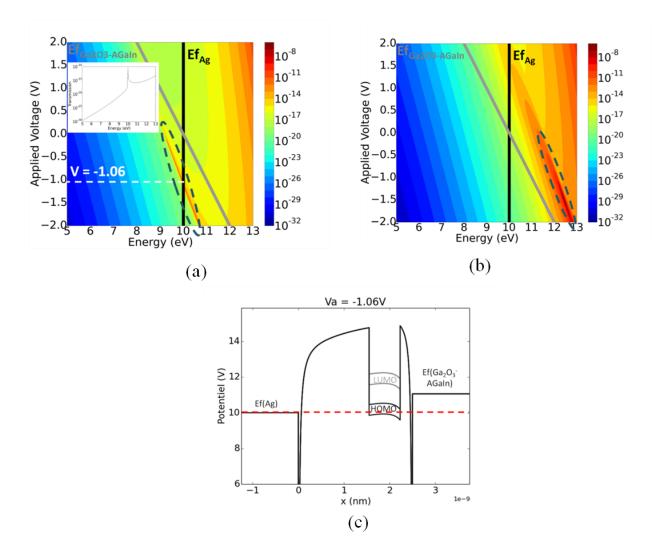


FIG. 3. The figures (a) and (b) present computed color maps of the tunneling probability for the HSC₁₁FC based junction (by considering $\Gamma_{HOMO} = \Gamma_{LUMO} = 0.6 \text{eV}$). The computations are performed considering (a) only the HOMO and (b) only the LUMO of the ferrocenyl moiety. The resonant states are surrounded by dashed lines. (c) Potential inside the HSC₁₁Fc based molecular diode at Va=-1.06V ($\Gamma_{HOMO} = \Gamma_{LUMO} = 0.6 \text{eV}$). The inset of the figure (a) shows the transmission probability versus energy for Va=-1.06 eV.

The figure 3(a) shows the computed tunneling probability for $\Gamma_{HOMO} = 0.6 \text{eV}$ ($\Gamma_{LU\ MO} = 0.6 \text{eV}$) and are performed by considering only the HOMO of the ferrocenyl moiety. It allows computing the J_{HOMO} current density. The results are shown in color maps giving the tunneling probability as functions of both the electron energy (x-axis) and the applied voltage (y-axis). The black and gray lines give the energy positions of the Fermi levels of the left Ag electrode and the right Ga_2O_3 –EGaIn electrode, respectively. The figure 3(a) reveals a sharp increase of the

tunneling probability for energies ranging between 9.2 eV and 11 eV and for voltages ranging between 0 and -2 V. This region is surrounded by a dashed line in figure 3(a). It corresponds to the presence of a resonant state in the HOMO of the ferrocenyl moiety. This resonance is shifted to higher energy values when the applied voltage is decreasing from 0 V to -2 V. It crosses the Fermi level of the left Ag electrode for Va = -1.06V. When Va is decreasing from 0 V to -2 V, this resonance is approaching more and more the Fermi level of the left Ag electrode[the black line in figure 3(a)]. Thus, the resonance participates more and more to the charge transportation. When the resonance is close enough to the Ag Fermi level (Va = -0.8 V) the current of the diode strongly increases [cf. figure 2(a)]. The current continues to sharply increase until the resonance rises into the window between the Fermi levels of the two electrodes. This resonance corresponds to a bound state in the HOMO, which becomes a quasi-bound state when its energy position is higher than the Fermi level of the left electrode¹². The inset of the figure 3(a) shows the transmission probability versus energy for an applied voltage of -1.06 eV. It clearly shows that a bound state, whose the energy position corresponds to the Fermi level of the left Ag electrode (10eV), exists. The figure 3(c) presents the potential inside the junction for HSC₁₁Fc based diodes at Va = -1.06 V and for $\Gamma_{HOMO} = \Gamma_{LUMO} = 0.6$ eV. The dashed red line shows the energy position of the bound state within the HOMO, which is equal to the Fermi level of the left electrode at Va = -1.06 eV. The figure 3(b) shows the calculated tunneling probability map by considering only the LUMO of the ferrocenyl moiety ($\Gamma_{LUM O} = 0.6 \text{ eV}$) and allows to compute the current density J_{LUMO}. It reveals the presence of a quasi-bound state (red line) at high energy (12 to 13 eV) and for negative applied voltage (0 to -2V). Because this resonance never falls within the window between the Fermi levels of both electrodes, it does not strongly participate to the charge transportation.

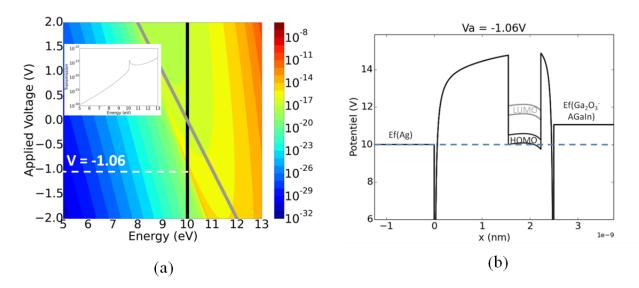


FIG.4. (a) Computed color map of the tunneling probability for the $HSC_{11}FC$ based junction by considering $\Gamma_{HOMO} = \Gamma_{LUMO} = 0.5$ eV. The computations are performed considering only the HOMO of the ferrocene moiety. (b) Potential inside the $HSC_{11}Fc$ based molecular diode at Va = -1.06 V ($\Gamma_{HOMO} = \Gamma_{LUMO} = 0.5 \text{ eV}$).

The figure 4(a) shows the calculated tunneling probability for $\Gamma_{\text{HOMO}} = 0.5 \text{ eV}$. As previously, these computations are performed by only considering the HOMO of the ferrocenyl moiety. In contrast to the previous results, the figure 4(a) does not reveal a sharp increase of the tunneling probability for energies ranging between 9.2 eV and 11 eV and for voltages ranging between 0 and -2 V. Thus, the resonant state coupling within the HOMO previously observed for Γ_{HOMO} = 0.6 eV is less pronounced for Γ_{HOMO} = 0.5 eV. The inset of the figure 4(a) shows the transmission probability versus energy for an applied voltage of -1.06 eV. The transmission probability at 10 eV is less sharp than previously. We explain these results by the fact that the resonant state cannot be coupled efficiently within the HOMO. The figure 4(b) gives the potential inside the HSC₁₁Fc based junction at Va = -1.06 V and for Γ_{HOMO} = 0.5eV and Γ_{LUMO} = 0.6 eV. The blue dashed line is located at the Fermi level of the left electrode, which corresponds to the energy level at which the bound state should be coupled. These results reveal that the bound state is not located within the HOMO. The figure 4(b) shows that the HOMO is located between the Fermi level of both electrodes at Va = -1.06 V. Thus, because the HOMO rises between the Fermi levels of both electrodes, we can observe a slight increase of current for applied voltages lower than -0.8 V (cf. figure 2(a)). Nevertheless, our results reveal that the HOMO is not large enough to allow a bound state appearing. It may explain why the asymmetry of the I(Va) characteristics is weakly pronounced for $\Gamma_{HOMO} = 0.5$ eV (cf. figure 2(a)).

These results are in accordance with the mechanism proposed by Nijhuis, Reus and Whitesides¹⁰ and by Cui et al. ¹³ for the current rectification by $HSC_{11}Fc$ SAM based molecular junctions. They suggested that the large rectification observed for $HC_{11}Fc$ molecular junctions originates from the accessible HOMO of the Fc moiety, which is asymmetrically positioned in the junction and electronically coupled to one electrode through non-uniform potential drops. According to recent theoretical works ¹⁶, our computations show that the molecular orbital width Γ_{HOMO} is an important parameter influencing the rectification ratio of the diodes. Furthermore, our results reveal that bound or quasi-bound states may play a crucial role in the charge transportation within $HSC_{11}Fc$ based molecular junctions.

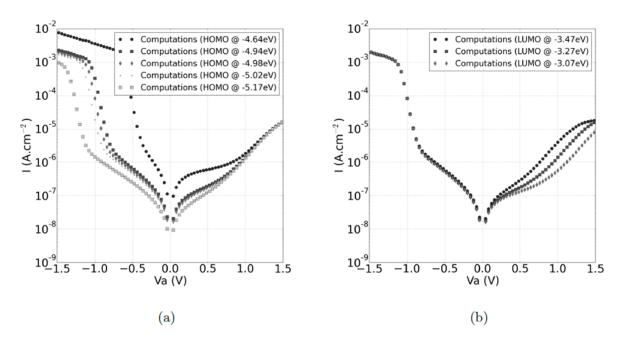


FIG. 5. Influence of the (a) HOMO and (b) LUMO energy positions on the I(Va) characteristic of the $HSC_{11}Fc$ based molecular junction.

B. Influence of the energy position

We investigate the influence of the energy position of the HOMO and LUMO on the electrical properties of $HSC_{11}Fc$ based diodes. For this purpose, the broadening of both the HOMO and LUMO levels are fixed ($\Gamma_{HOMO} = \Gamma_{LUM\ O} = 0.6\ eV$). The energy position of the HOMO is first varied between -4.64 eV and -5.17 eV while the energy position of the LUMO is kept constant at -3.27 eV. The figure 5(a) shows that the strong current increase in the junction is shifted to lower negative applied voltages (Va) when the energy position of the HOMO is decreasing. In other words, when the energy position of the HOMO is decreasing, a stronger negative applied voltage is required to raise the HOMO between the Fermi levels of both electrodes. Then, the energy position of the LUMO is varied between -3.47 eV and -3.07eV while the energy position of the HOMO is kept at -4.97 eV. The results are shown in figure 5(b) and reveal that the energy position of the LUMO mainly influences the slope of the I(Va) curve at positive bias. Thus, the closer is the LUMO to the Fermi level of the right electrode, the lower is the resistivity of the junction at positive bias. These results show that the HOMO electrode work function offset strongly influences the diode rectification ratios.

C. Influence of the alkyl chain length

Finally, the energy level positions and the level broadenings are adjusted to fit the experimental I(Va) characteristics obtained by Nijhuis, Reus and Whitesides¹⁰. For the HOMO, the obtained energy position and broadening are -4.955 eV and 0.57 eV, respectively. For the LUMO, the obtained energy position and broadening are -3.27 eV and 0.57eV, respectively. The distance between the end of the molecule and the right electrode is adjusted at 0.27 nm. The figure 6(a) shows that the computed I(Va) characteristic of the HSC₁₁Fc based junction agrees quite well with experimental measurements. The calculated RR (from equation 1) between Va=-1 V and Va=1 V is 109 while Nijhuis, Reus and Whitesides experimentally obtained a RR of 100¹⁰. The figure 6(b) depicts the computed I(Va) characteristic of a HSC₉FC based molecular diodes. As shown in figure 1(b) and 1(c), while the whole length of HSC₁₁ including the covalent bond (S-Ag) is 1.55 nm, the length of HSC₉ is reduced to 1.35 nm¹⁰. The other parameters are identical to those used for the HSC₁₁Fc based molecular diode. The computed I(Va) curve reproduces quite well the Nijhuis, Reus and Whiteside's experimental data ²³ and reveals a strong increase of

current at reverse bias. The calculated RR between Va=-1 V and Va=1 V is 26 while Nijhuis, Reus and Whitesides experimentally obtained a RR of 10¹⁰. The figure 6(c) shows the color map of the tunneling probability computed for the HSC₉Fc based diode and performed by only considering the HOMO of the ferrocenyl moiety. This figure reveals a resonant state for energies ranging between 9.2 eV and 11 eV and for voltages ranging between 0 and -2 V. While this resonance is crossing the Fermi level of the left Ag electrode at Va=-1.06 eV in the case of HSC₁₁Fc, it now crosses the Fermi level of the left Ag electrode at Va=-1.13 V. Thus, the resonant state rises between the Fermi levels of both electrodes at lower negative voltages and the calculated rectification ratio of the HSC₉Fc based diode is lower than the one of the HSC₁₁Fc diode.

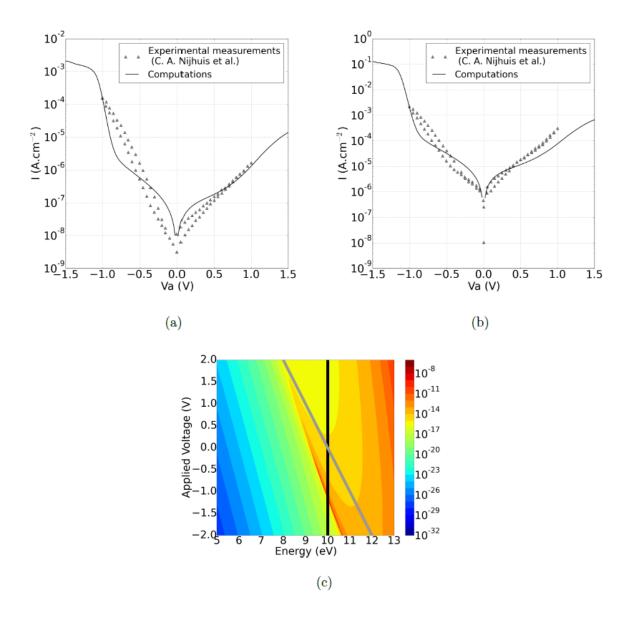


FIG.6. Comparison between computed I(Va) characteristics and experimental measurement obtained by Nijhuis, Reus and Whitesides ¹⁰ for (a) a HSC₁₁Fc based molecular junction and (b) a HSC₉Fc based molecular junction. (c) is a color map of the tunneling probability for the HSC₉FC based molecular diode ($\Gamma_{HOMO} = 0.57eV$ and $\Gamma_{LUMO} = 0.6eV$)).

IV. Influence of the ferrocenyl position within the molecular junction

In this section, we investigate the influence of the ferrocenyl position within the molecular junction on the rectifying properties of the molecular diodes. The figure 1(d) gives the theoretical band diagram of HSCiFcC13-i based molecular diodes having Ag and Ga₂O₃–EgGaIn electrodes. Both the CH₃ and Fc end groups form Van der Waals interactions with the

Ga₂O₃-EgGaIn electrode and the sulfur forms a covalent bounding with the Ag electrode. Our model does not take into account the fact that the broadening of the HOMO level may increase exponentially when the Fc moiety is very close to the Ag electrode¹⁶. Nevertheless, as it will be presented in the following, this model is able to reproduce the main electrical behavior of the HSCiFcC13-i based molecular diodes which tends to prove that the asymmetry of barrier lengths at both sides of the HOMO also strongly contributes to the rectifying properties of the junctions.

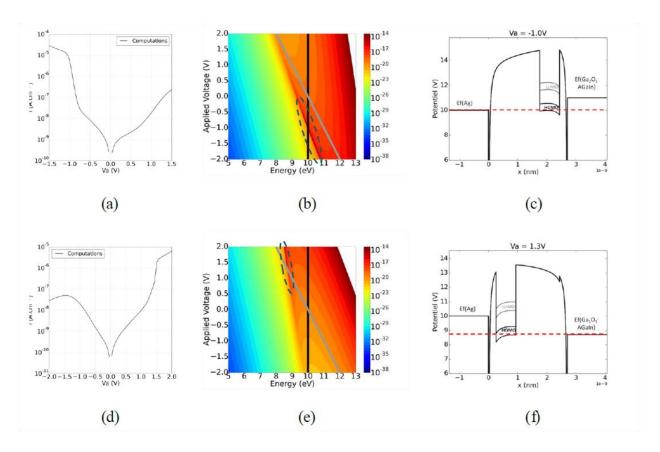


FIG. 7. Computed (a) I(Va) characteristics, (b) color map of the tunneling probability and (c) potential inside the molecular junction for a $HSC_{13}Fc$ based diode. Computed (d) I(Va) characteristics, (e) color map of the tunneling probability and (f) potential inside the molecular junction for a $HSFcC_{13}$ based diode.

As previously, the HOMO energy position and broadening are fixed at -4.955 eV and 0.57 eV, respectively. These values are in strong accordance with the values obtained from experimental UPS measurements. Indeed, a HOMO energy position around - 5eV and a HOMO broadening between 0.5eV and 0.75eV have been obtained from UPS measurements ^{11,16}. The figures 7(a) and 7(d) show the computed I(Va) characteristics of HSC₁₃Fc and HSFcC₁₃ based molecular

junctions respectively. In accordance with the experimental measurements obtained by Nijhuis et al. 11, while the HSFcC₁₃ based diode rectifies the current at forward bias the HSC₁₃Fc based diode rectifies the current at opposite bias. The figures 7(b) and 7(e) show the color map of the tunneling probability computed for the HSC₁₃Fc and HSFcC₁₃ based diodes respectively. These computations are performed by considering only the HOMO of the ferrocenyl moiety. As previously, the figure 7(b) reveals bound and quasi-bound states within the HOMO of the Fc moiety for negative bias. This resonant state crosses the Fermi level of the left Ag electrode at Va=-1.0 V and is responsible for the strong increase of current at negative bias. The figure 7(c) gives the potential inside the junction at Va=-1.0 V. The red dashed line is located at the Fermi energy level of the left Ag electrode which is equal to the energy position of the resonant state at Va=-1.0eV. The figure 7(e) gives the color map of the tunneling probability of the HSFcC13 based junction. In this case, we observe bound and quasi-bound states at positive bias. This resonant state crosses the Fermi level of the right Ga₂O₃-EgGaIn electrode at Va=1.3 V and is responsible of the strong increase of current at positive bias. When Va is increasing from 0V, the HOMO enters in the window between both electrodes and the resonant state is approaching more and more the Fermi level of the right Ga₂O₃-EgGaIn electrode. When the resonance is close enough to the Ga₂O₃-EgGaIn Fermi level, the diode current strongly increases. The current continues to sharply increase until the resonance falls into the window between the Fermi levels of the two electrodes. The figure 7(f) gives the potential inside the junction at Va = 1.3 V. The red dashed line is located at the Fermi energy level of the right Ga₂O₃–EgGaIn electrode which is equal to the energy position of the resonant state at Va = 1.3 V.

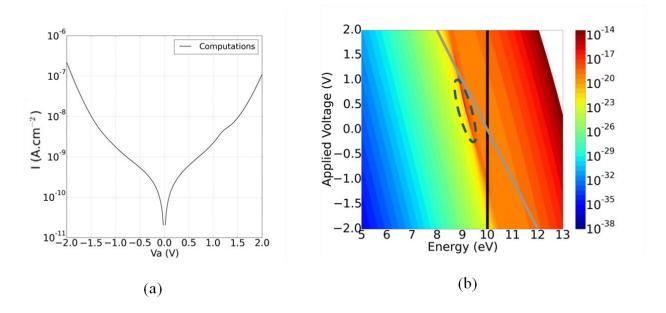


FIG.8. Computed (a) I(Va) characteristics and (b) color map of the tunneling probability of a HSC_6FcC_7 based diode.

The figure 8(a) shows the computed I(Va) characteristic of a HSC_6FcC_7 based diode ($\Gamma_{LUMO} = \Gamma_{HOMO} = 0.53 eV$). In this configuration, the Fc moiety is separated from both electrodes by an alkyl chain (cf. 1(d)). In accordance with the experimental results obtained by Nijhuis et al. 11, the I(Va) characteristic is highly symmetric and the diode exhibits a rectification ratio close to unity (no rectification). The figure 8(b) shows the color map of the tunneling probability through the junction by considering only the HOMO of the ferrocenyl moiety. The figure 8(b) reveals a bound state within the HOMO of the Fc moiety for negative and positive bias. This resonant states does not cross any electrode Fermi level in the considered range of applied voltages. Thus, they do not participate actively to the charge transportation either at positive voltages or at negative voltages which nicely explains why the I(Va) curveis symmetric. In other words, the accessible HOMO of the Fc moiety is symmetrically positioned in the junction, which results in a symmetric electronic coupling to both electrodes. The potential drop within the junction is too low to ensure that the bound state enters in the window between the Fermi levels of the electrodes.

V. Conclusion

We have developed a simple but efficient and reliable 1D multiband quantum transport model considering both the HOMO and LUMO levels to investigate the electrical properties of molecular diodes made of ferrocenyl-alkanethiols. Our results suggest that the large rectification ratio observed for HC11Fc molecular junctions originates from the accessible HOMO of the Fc moiety which is asymmetrically positioned in the junction and electronically coupled to one electrode through non-uniform potential drops. Our results reveal that bound or quasi-bound states play an important role in the charge transportation in the molecular diodes. The computed I(Va) characteristics of HSC11Fc and HSC9Fc based junctions agree well with experimental measurements obtained by Nijhuis, Reus and Whitesides¹⁰. The calculated RR between Va = -1 V and Va = 1 V are 109 and 26 for HSC11Fc and HSC9Fc based junctions respectively while Whiteside et al. experimentally obtained RR of 100 and 10 for HSC11Fc and HSC9Fc based junctions, respectively 10. We show that our model allows explaining and predicting the electrical properties of molecular diodes made of HSCiFcC13-i. In accordance with the experimental results obtained by L. Yuan et al. 11, we show that the direction of rectification depends on the position of the Fc units within the alkyl chain of ferrocenyl-alkanethiol. Finally, our model allows extracting electronic properties of the ferrocenylalkanethiol such as the orbital energy positions and the orbital widths. Furthermore, this model has the advantage that it does not require DFT or TD-DFT time consuming computations.

Acknowledgements:

This work has been carried out thanks to the support of the A*MIDEX project (n° ANR- 11-IDEX-0001-02) funded by the "Investissements d'Avenir" French Government program, managed by the French National Research Agency (ANR).

REFERENCES

¹ A. Aviram and M. A. Ratner, Chem. Phys. Lett. 29, 277 (1974).

² G. Ashwell and A. Mohib, J. Am. Chem. Soc. 127 (46), 16238 (2005).

³ E. L"ortscher, V. Geskin, B. Gotsmann, J. Fock, J. Sorensen, T. Bjornholm, J. Cornil, H. van der Zant, and H. Riel, Small 9 (2), 209 (2013).

⁴ H. Vazquez, R. Skouta, S. Schneebeli, M. Kamenetska, R. Breslow, L. Venkataraman, and M. Hybertsen, Nat. Nanotechnol. 7 (10), 663 (2012).

- ⁵ X. Chen, S. Yeganeh, L. Qin, S. Li, C. Xue, A. Braunschweig, G. Schatz, M. Ratner, and C. Mirkin, Nano Lett. 9 (12), 3974 (2009).
- ⁶ A. D. McFarland and R. P. V. Duyne, Nano Lett. 3, 1057 (2003).
- ⁷ J. C. Love, L. A. Estroff, J. K. Kriebel, R. G. Nuzzo, and G. M. Whitesides, Chem. Rev. 2 105, 1103 (2005).
- ⁸ D. Goswami, S. Vijayaraghavan, S. Lu, and G. Tamm, Solar Energy 76, 33 (2004).
- ⁹ J. M. Nunzi, proc of SPIE 7712 (2010).
- ¹⁰ C. A. Nijhuis, W. F. Reus, and G. M. Whitesides, J. AM. CHEM. SOC. 132, 18386 (2010).
- ¹¹ L. Yuan, N. Nerngchamnong, L. Cao, H. Hamoudi, E. del Barco, M. Roemer, R. K. Sriramula, D. Thompson, and C. A. Nijhuis, Nature Communication 6:6324 (2015).
- ¹² A. K. Ghatak, K. Thyagarajan, and M. R. Shenoy, IEEE Journal of Quantum Electronics 24:8, 1524 (1988).
- ¹³ B. Cui, Y. Xu, G. Ji, H. Wang, W. Zhao, Y. Zhai, D. Li, and D. Liu, Organic Electronics 15, 484 (2014).
- ¹⁴ S. Grover and G. Moddel, Solid-State Electronics 67, 4 (2012).
- ¹⁵ H. B. Akkerman, R. C. G. Naber, B. Jongbloed, P. A. van Hal, P. W. M. Blom, D. M. de Leeuw, and B. de Boer, PNAS 104, 11161 (2007).
- ¹⁶ A. R. Garrigues, L. Yuan, L. Wang, E. R. Mucciolo, D. Thompon, E. del Barco, and C. A. Nijhuis, Scientific Reports 6:26517 (2016).
- ¹⁷ J. G. Simmons, J ApplPhys 34(6), 1793 (1963).
- ¹⁸ O. M. Probst, Am J Phys 70(11, 1110 (2002).
- ¹⁹ J. G. Simmons, J Phys D ApplPhys 4(5), 613 (1971).
- 20 N. Armstrong, R. C. Hoft, A. McDonagh, M. B. Cortie, and M. J. Ford, Nano Letters 7, 10 3018 (2007).
- ²¹ A. Salomon, D. Cahen, S. Lindsay, J. Tomfohr, V. B. Engelkes, and C. D. Frisbie, Adv. Mater. 15, 1881 (2003).
- ²² K. Moth-Poulsen and T. bjornholm, Nature Nanotechnology 4, 551 (2009).
- ²³ C. A. Nijhuis, W. F. Reus, and G. M. Whitesides, J. Am. Chem. Soc. 132, 18386 (2010).